

Introduction to MEMS Design and Fabrication

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A brief history of MEMS

- 1750s first electrostatic motors (Benjamin Franklin, Andrew Gordon)
- 1824 Silicon discovered (Berzelius)
- 1927 Field effect transistor patented (Lilienfeld)
- 1947 invention of the transistor (made from germanium)
- 1954 Smith, C.S., "Piezoresistive effect in Germanium and Silicon, Physical Review, 94.1, April 1954.
- 1958 silicon strain gauges commercially available
- 1961 first silicon pressure sensor demonstrated (Kulite)
- 1967 Invention of surface micromachining (Nathanson, Resonant Gate Transistor)
- 1970 first silicon accelerometer demonstrated (Kulite)
- 1977 first capacitive pressure sensor (Stanford)
- 1980 Petersen, K.E., "Silicon Torsional Scanning Mirror", IBM J. R&D, v24, p631, 1980.
- 1982 disposable blood pressure transducer (Foxboro/ICT, Honeywell, \$40)
- 1982 active on-chip signal conditioning
- 1984? First polysilicon MEMS device (Howe, Muller)
- 1988 Rotary electrostatic side drive motors (Fan, Tai, Muller)
- 1989 Lateral comb drive (Tang, Nguyen, Howe)
- 1991 polysilicon hinge (Pister, Judy, Burgett, Fearing)
- 1992 Grating light modulator (Solgaard, Sandejas, Bloom)
- 1992 MCNC starts MUMPS
- 1993? first surface micromachined accelerometer sold (Analog Devices, ADXL50)
- 1994 XeF2 used for MEMS (OK, so this one isn't as important as the others)

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References

- Books

- Elwenspoek and Jansen, Silicon Micromachining, Cambridge
- Keller, Microfabricated High Aspect Ratio Silicon Flexures, MEMS Precision Instruments
- Kovacs, Micromachined Transducers Sourcebook, McGraw-Hill
- Madou, Fundamentals of Microfabrication, CRC
- Maluf, An Introduction to Microelectromechanical Systems Engineering, Artech House
- Ristic, Sensor Technology and Devices, Artec House
- Senturia, Microsystem Design, Kluwer
- Sze, Semiconductor Sensors, Wiley

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References

- Conferences

- Sensors and Actuators Workshop (Hilton Head), even years, Hilton Head Island, SC. N. America only
- IEEE MEMS workshop, annual, 00 Japan, 01 Europe, 02 U.S.
- Intl. Conf. Solid State Sensors and Actuators (Transducers), odd years, 99 Japan, 01 Europe, 03 U.S.
- MOEMS, 97 Japan, 98 U.S. (LEOS), 99 Germany
- SPIE, annual, San Jose, CA. (formerly Austin, TX)
- LEOS, OSA, CLEO
- ASME
- ...

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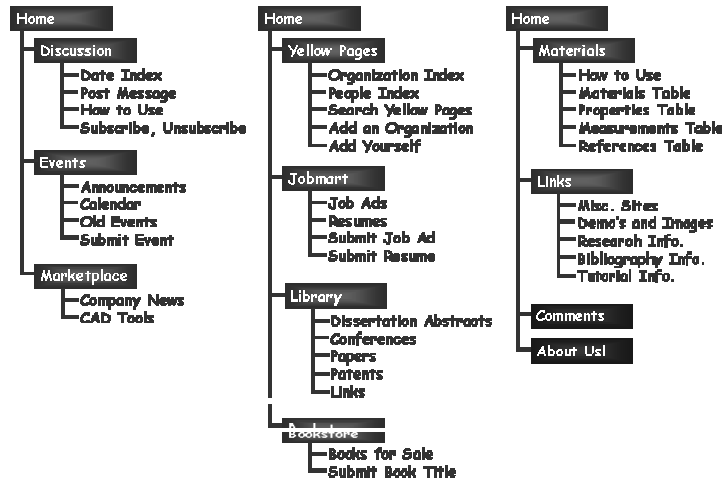
References

- Periodicals
 - IEEE/ASME, JMEMS
 - Sensors and Actuators A/B
 - J. Micromechanics and Microengineering
 - Sensors and Materials
- Articles
 - Petersen, *Silicon as a Mechanical Material*, Proc. IEEE, V70 pp.420-457, 1982.
 - Proc. IEEE V86N8, 1998 Special issue on MEMS
 - Wu, *Micromachining for Optical and Optoelectronic Systems*, Proc. IEEE V85N11 pp.1833-1856, 1997.

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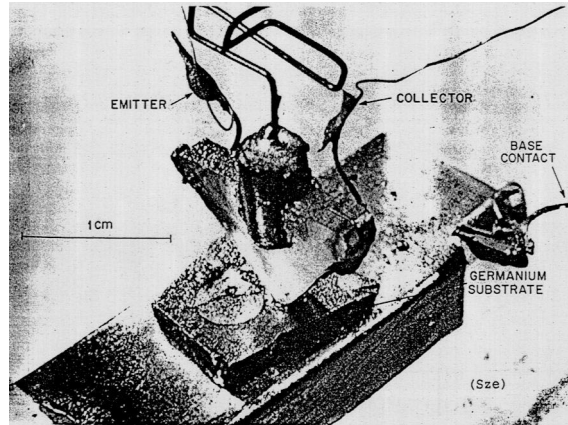


[Http://mems.isi.edu](http://mems.isi.edu) - probably the best overall MEMS site on the web. Materials database, bibliography are great.

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Early Semiconductor Fabrication



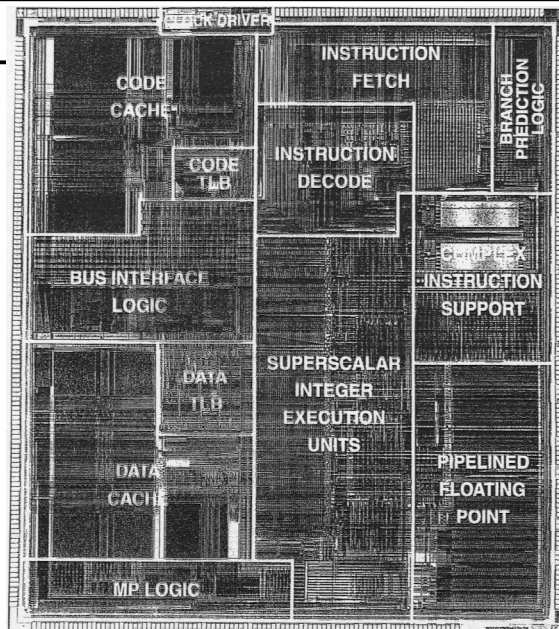
J. Bardeen, W.H. Brattain, "The first transistor, a semiconductor triode", Phys. Rev., 74, 230 (1948).

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Intel 133 MHz Pentium Processor

3.3 million transistors
0.35 micron lithography
4 layer metalization
First silicon: May 1995



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Fabrication

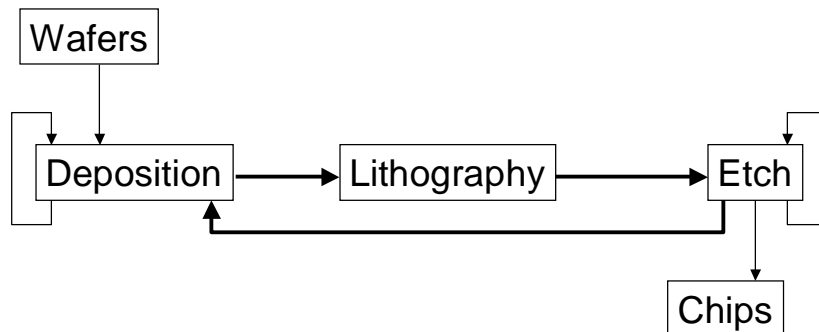
- IC Fabrication
 - Deposition
 - Lithography
 - Removal
- Bulk micromachining
 - Crystal planes
 - Anisotropic etching
 - Deep Reactive Ion Etching
- Surface micromachining
 - Sacrificial etching
 - Molding
 - Bonding

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Process Flow

- Integrated Circuits and MEMS identical
- Process complexity/yield related to # trips through central loop



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Materials

- Metals
 - Al, Au, Cu, W, Ni, TiNi, NiFe,
- Insulators
 - SiO₂ - thermally grown or vapor deposited (CVD)
 - Si₃N₄ - CVD
- Polymers
- The King of Semiconductors: Silicon
 - stronger than steel, lighter than aluminum
 - single crystal or polycrystalline
 - 10nm to 10mm

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Applications

- Pressure sensors
 - Automotive, Medical, Industrial, ...
- Accelerometers
 - Automotive, Medical, Industrial
- Gyros
 - Automotive
- Displays
 - TI DMD, SLM GLV
- Fiber optics
 - Switches, attenuators, alignment
- RF components
 - Relays, tunable passives elements
- Biomedicine
 - Drug delivery, DNA sequencing, chemical analysis

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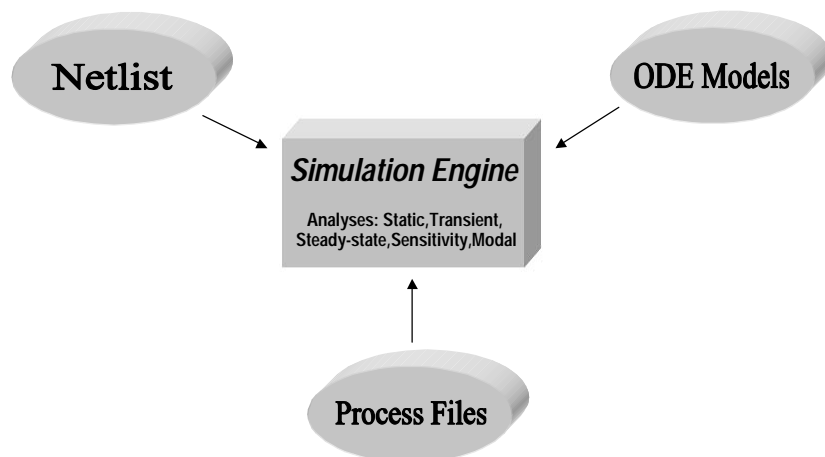
Course content

- Fabrication
 - Materials, geometry
 - Compatibility, integration
- Physics
 - Beam theory, electrostatics, thermal, fluidic, ...
- Design
 - Combs, springs, hinges
 - Resonators, accelerometers, gyros
 - Scanning mirrors

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SUGAR: Spice-like environment



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